Strain effects on the spectra of spontaneously ordered Ga x In1-x P Gi <i U]'K Y]'UbX'5'YI 'Ni b['Yf'

## Strain offects on the spectra of spentaneously ordered Co. In

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Spontaneous (111) CuPt-like ordering has been widely observed in  $Ga_xIn_{1-x}P$  lattice matched  $(x=x_0)$  to a GaAs(001) substrate. This leads to a band-gap reduction  $\Delta E_g$  and to a valence-band splitting  $\Delta E_{12}$ . We explore here the consequence of the coexistence of (001) epitaxial strain (produced by selecting  $x \neq x_0$ ) and (111) chemical ordering. This leads to distinct changes in  $\Delta E_g$  and  $\Delta E_{12}$  which could serve as new fingerprints of ordering.

Surface reconstruction-induced ordering<sup>1</sup> of III-V alloys leads to lowering of the band gap<sup>1-5</sup> and to splitting of the

band is the sixfold degenerate  $\Gamma_{15v}$  state while the direct conduction-band minimum is the  $\Gamma_{1c}$  doublet. The degen-

partially ordered alloys, and have been seen in electroreflectance, polarized photoluminescence, polarized photoluminescence, polarized

splittings are denoted  $\Delta^{SO}$ ,  $\Delta^{O}_{111}$ , and  $\Delta^{S}_{001}$ , respectively. We will next describe their effects on the Hamiltonian assuming

the graving Go In P film was adjusted to the value

the cir unlance states (ut ut at at all ul)

strate. Consequently, in the absence of strain, both the band-

and ordering effects do not distinguish spin up and spin

chemical ordering soon independently in 1900-19

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pure misfit strain  $(x \neq x_0)$  can also lead to valence-band splitting<sup>8</sup> and to band-gap changes.<sup>9</sup> In this letter we thus focus on the interesting case of the coexistence of chemical ordering in the direction  $G_{\text{ord}}$  with epitaxial strain  $(x \neq x_0)$  in the direction  $G_{\text{substrate}}$ . This is different from the case of artificially grown strain layer superlattices in which the direction of strain, so these effects add up colinearly. In contrast, in spontaneously ordered alloys the direction of chemical ordering  $G_{\text{ord}}$ =(111) is different from the substrate orientation

$$H_{001,\nu}^{S}(\epsilon) = a_{\nu} \frac{\Delta V(\epsilon)}{V} + \frac{1}{3} \Delta_{001}^{S}(\epsilon) \begin{pmatrix} 1 & 0 & 0 \\ 0 & 1 & 0 \\ 0 & 0 & -2 \end{pmatrix}.$$
(1)

Here,  $a_v$  is the hydrostatic deformation potential of the valence band,  $\Delta V(\epsilon)/V$  is the relative volume change, and  $\Delta_{001}^S(\epsilon) = 3b[(C_{11} + 2C_{12})/C_{11}]\epsilon$  is the crystal field splitting, where b is the tetragonal deformation potential and  $C_{ij}$  are the elastic constants

spinting  $\Delta E_{12}$ , and the functional interrelationship  $\Delta E_g$  vs  $\Delta E_{12}$  between them.

 $G_{\text{spherote}} \cong (001)$ . We will show that this noncolinear "vector

In imperfectly ordered  $Ga_xIn_{1-x}P$  alloy, successive (111) cation planes are not pure Ga and pure In, respectively, but

$$H_{111,\nu}^O(\eta) = B_{\nu}(\eta) + \frac{1}{3} \Delta_{111}^O(\eta) \begin{pmatrix} 0 & -1 & -1 \\ - & 0 & -1 \end{pmatrix}.$$

Here,  $B_v$  is the ordering-induced shift of the valence-band

energy center while  $\Delta_{111}^O(\eta) = \Delta_{111}^O(\eta = 1) \eta^2$  are the ordering-induced crystal filed splitting. Placing  $H_{001,\nu}^S$  and

degree of CuPt-type order is described by the long-range

(2)

to the growth direction) is  $\epsilon(x) = [a_s - a_f(x)]/a_f(x)$ , where  $a_f(x)$  and  $a_s$  are the lattice constants of the film and the substrate, respectively. All of our quantities will thus be denoted by the degree of order  $\eta$  and the strain  $\epsilon(x)$ . The band-gap reduction of the strained and ordered alloy  $\Delta E_g(\eta, \epsilon) = E_g(\eta, \epsilon) - E_g(0,0)$  is measured with respect to

 $H_{111,v}^O$  on the two diagonal 3×3 blocks and adding the full 6×6 spin-orbit matrix, <sup>10</sup> relative to the energy center of the

composition. In this reference system, the top of the valence

ordering plus (001) strain are:

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strain  $\epsilon$ ) and degree of ordering  $\eta$ .

The energy for the conduction (c) band minimum is given by

$$E_{c}(\eta,\epsilon) = E_{c}(0,0) + a_{c} \frac{\Delta V(\epsilon)}{\tau \epsilon} + B_{c}(\eta). \tag{4}$$

mere, E (0,0) is the conduction-band energy of the strainfree random alloy at composition x,  $a_c$  is the deformation potential of the conduction band, and  $B_c$  is the orderinginduced conduction-band energy shift. Since only relative energy difference between two bands are generally measured, it is convenient to define the center of the three top of valence-band energies as our zero of energy and denote by  $a = a_c - a_v$  and  $B = B_c - B_v$  as the deformation energies of the average band gap  $\bar{E}_g = E_c - \frac{1}{3}(E_1 + E_2 + E_3)$ . For (001) strain the relative volume change is given by  $\Delta V(\epsilon)/V = 2[(C_{11} - C_{12})/C_{11}]\epsilon$ . The ordering induced average band-gap change is given by  $B(\eta) = [\Delta E_g(1,0)]$  $+\frac{1}{3}\Delta_{111}^{O}(1,0)$ ]  $\eta^2$ , where  $\Delta E_g(1,0)$  is the band-gap reduction of the strain-free and fully order alloy relative to the perfectly random alloy. Hence, the conduction-band energy of Eq. (4) can be written as

$$E_{c}(\eta, \epsilon) = E_{g}(0,0) + \frac{1}{3}\Delta^{SO} + 2a \frac{C_{11} - C_{12}}{C_{11}}\epsilon + \left[\Delta E_{g}(1,0) + \frac{1}{3}\Delta^{O}_{111}(1,0)\right]\eta^{2}.$$
 (5)

The needed input data for evaluating Eqs. (3) and (5) are (i) the concentration dependent properties:  $E_g(x)$ ,  $\epsilon(x)$ ,  $\Delta^{SO}(x)$ ,  $C_{ij}(x)$ , a(x), and b(x) of the random alloy  $(\eta=0)$  and (ii) the ordering dependent properties:  $\Delta^O_{111}(1,0)$  and

calculate band-edge energy levels of  $Ga_xIn_{1-x}P$  as function of strain and ordering.

Properties	GaP	InP
a <sub>0</sub> (Å)	5.4512	5.8687
	2.78	1.35
$E_{g}$ (eV) $\Delta^{SO}$ (eV)	0.08	0.11
C <sub>11</sub> (Gpa)	141	102
C. (Gna)	62	58
b (eV)	-1.8	-1.6

assuming the usual quadratic bowing form

$$P(x) = xP(GaP) + (1-x)P(InP) - b_P x(1-x),$$
 (6)

where  $b_P$  is the bowing parameters for property P. For the spin-orbit splitting we use the bowing  $b_A$ so=-0.02 eV,

and deformation potentials. These input values for  $Ga_xIn_{1-x}P$  are given in Table I. For the second category of quantities, we use our previously calculated band structure values  $^7\Delta^O_{111}(1,0)=0.20$  eV and  $\Delta E_g(1,0)=-0.32$  eV.

Using these input data we solve Eqs. (3) and (5), obtaining (a) the band-gap reduction  $\Delta E_g[\eta, \epsilon(x)]$  and (b) the valence-band splitting  $\Delta E_{12}[\eta, \epsilon(x)] = E_1[\eta, \epsilon(x)] - E_2[\eta, \epsilon(x)]$ . Figure 1 depicts these quantities as a function of the film composition x, while Fig. 2 shows them as a function of the degree  $\eta$  of long range order. The following are the important features:

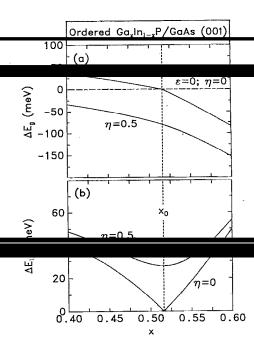
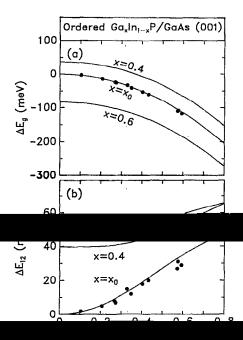


FIG. 1. (a) The band-gap reduction  $\Delta E_g(\eta, \epsilon) = E_g[\eta, \epsilon(x)] - E_g[0, 0]$  as a function of composition x at n=0 and n=0.5. The dashed horizontal line

valence-band splitting  $\Delta E_{12}$  of the strained alloy with ordering as function of composition x at  $\eta$ =0 and  $\eta$ =0.5.



tary, so the combined effect is larger than the individual one.

(d) It is useful to plot the measured  $\Delta E_g$  vs  $\Delta E_{12}$  (Fig. 3). There are three domains in this plane: If the measured data

 $-\Delta E_g(\eta)$  (meV)

=0.6

200

80

calculated  $x = x_0$  line, *epitaxial strain* is the logical cause as

 $\Delta E_{12}$  vs x and the  $\Delta E_g$  vs x (or  $E_g$  vs x) curves have a cusp at  $x=x_0$ , reflecting the change of the VBM from light hole when  $x< x_0$  to heavy hole when  $x>x_0$ . (c) The slope  $\alpha$  for the light-hole gap  $E_g$  vs x is much smaller than the slope  $\beta$  for the heavy-hole gap. These features have been observed in strained random alloys of GaInP<sup>9</sup> and GaInAs.<sup>9</sup>

(ii) Pure chemical ordering with no strain  $(x=x_0; \eta \neq 0,$ 

data fall below the line (as is the case for the high  $|\Delta E_g|$  samples of Fig. 3), we have an effect that produce a lowering in the band gap without a concomitantly large valence-band

circles in Fig. 2 show the recent prezonoumated renectivity data of Alonso  $et\ al.^4$  We find that the  $\eta$  which fits the theoretical  $\Delta E_g$  also fits the theoretical  $\Delta E_{12}$  of the same samples. This then gives a "self-consistent" way of deducing  $\eta$  from optical measurements.<sup>7</sup> (b) For the valence-band splitting, chemical ordering is analogous to compressive strain in that both yield a light-hole state at the top of the valence band. This ordering-induced reduction of the in-plan effective mass at the valence-band top (relative to the

(iii) Coexistence of chemical ordering with epitaxial

 $(x \neq x_0)$  is predicted to remove the cusp in the  $\Delta E_g$  vs x and

random alloy) would lead to larger exciton radii.

predicted to reduce the dependence of  $\Delta E_{12}$  on x, as illustrated by the flattening of the  $\eta$ =0.5 curve near x= $x_0$  in Fig. 1(b). (c) (001) strain increases the valence-band splitting produced by pure ordering, and vise versa [Figs. 1(b) and 2(b)].

tion.

In summary, we have shown that measurements of  $\Delta E_g$  and  $\Delta E_{12}$  of  $\mathrm{Ga}_x\mathrm{In}_{1-x}\mathrm{P}$  films mismatched with the  $\mathrm{GaAs}(001)$  can be used to observe new fingerprints of ordering. This includes the "rounding of the cusp" of  $\Delta E_{12}$  vs x, flattening of the  $\Delta E_{12}$  vs x curve, and the shifts in the  $\Delta E_g$  vs  $\Delta E_{12}$  curve. These predictions await experimental testing

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